

In the Specification

At page 1 before the "Technical Field" section, please insert the following:

--RELATED PATENT DATA

This patent resulted from a divisional application of U.S. Patent Application Serial No. 10/293,072, filed November 12, 2002, entitled "Atomic Layer Deposition Methods", naming Trung Tri Doan, Guy T. Blalock, and Gurtej S. Sandhu as inventors, the disclosure of which is incorporated by reference.--

In the Claims

Cancel claims 1-63.

REMARKS

This application is a divisional application of U.S. Patent Application Serial No.10/293,072. Original claims 1-63 have been cancelled without prejudice. Claims 64-99 remain in the application for consideration.

Respectfully submitted,

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By: 
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